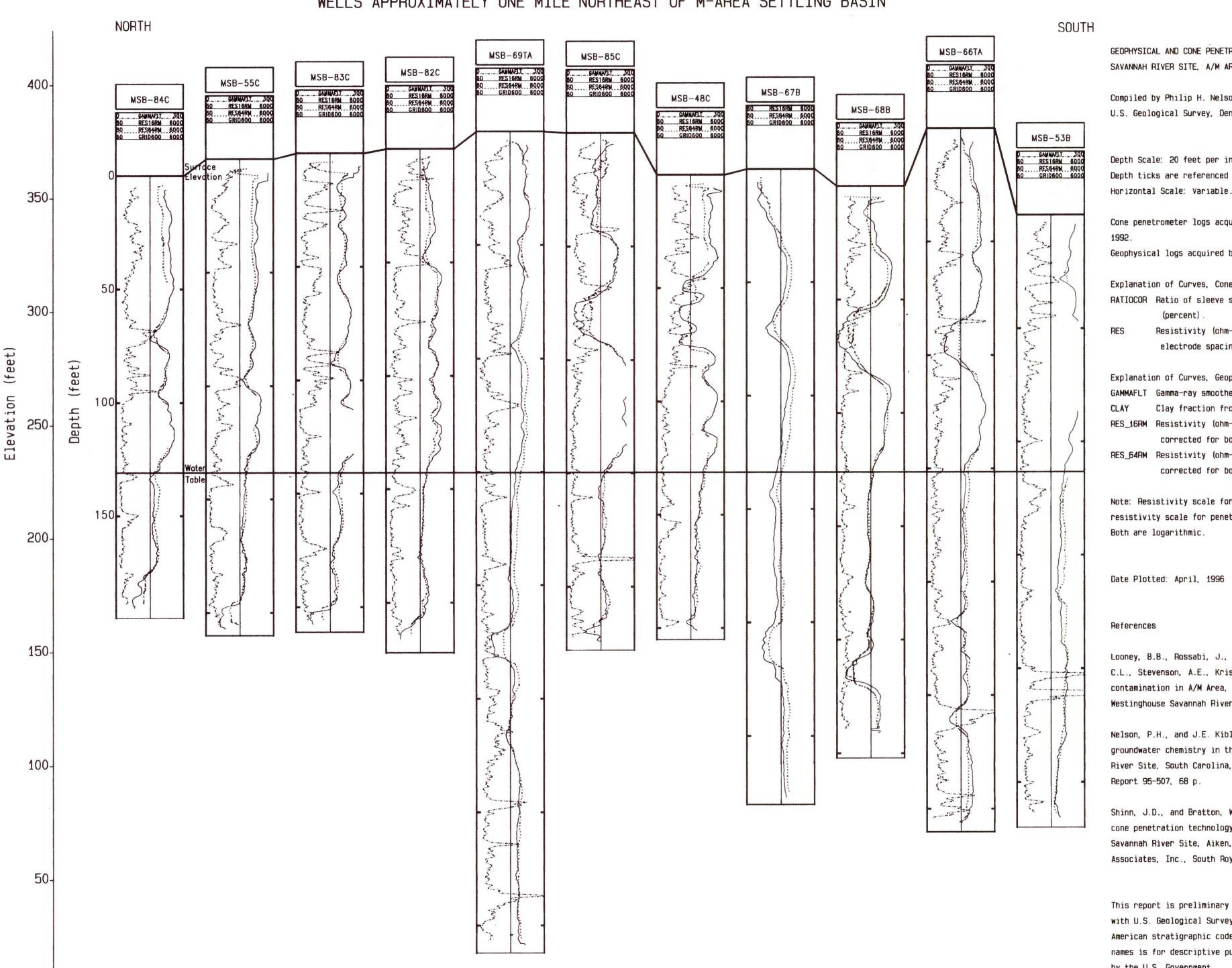
WELLS APPROXIMATELY ONE MILE NORTHEAST OF M-AREA SETTLING BASIN



GEOPHYSICAL AND CONE PENETROMETER LOGS SAVANNAH RIVER SITE, A/M AREA

Compiled by Philip H. Nelson and Joyce E. Kibler U.S. Geological Survey, Denver CO

Depth Scale: 20 feet per inch. Depth ticks are referenced to surface for each well.

Cone penetrometer logs acquired by Applied Research Associates,

Geophysical logs acquired by Graves and Grayco, 1988-1992.

Explanation of Curves, Cone Penetrometer Runs (CPT-) RATIOCOR Ratio of sleeve stress to corrected tip stress

Resistivity (ohm-m) from Wenner array with one-inch electrode spacings.

Explanation of Curves, Geophysical Logs (MSB- and MHT-)

GAMMAFLT Gamma-ray smoothed over 11 samples (1.1 feet)

Clay fraction from drilling samples.

RES_16RM Resistivity (ohm-m) from 16-inch normal array, corrected for borehole fluid.

RES_64RM Resistivity (ohm-m) from 64-inch normal array. corrected for borehole fluid.

Note: Resistivity scale for geophysical logs is 60-600-6000 ohm-m; resistivity scale for penetrometer log is 30-300-3000-30,000 ohm-m.

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